



JAPAN PATENT OFFICE



STUDY PROGRAM

WIPO/IP/TYO/10/INF/3
ORIGINAL: ENGLISH
DATE: NOVEMBER 2010

Global Intellectual Property (IP) Protection Systems with Particular Reference to the Patent Cooperation Treaty (PCT) System and the Madrid System for the International Registration of Marks

organized by

the World Intellectual Property Organization (WIPO)

in cooperation with

the Japan Patent Office (JPO)

Tokyo, Japan, November 11 and 12, 2010

LIST OF PARTICIPANTS

prepared by the International Bureau of WIPO

I. PARTICIPANTS

CHINA

Xiang LI, Deputy Director, PCT1 Division, State Intellectual Property Office of the People's Republic of China, Beijing

Xue WEN, Deputy Director, International Registration Division, State Administration for Industry and Commerce of the People's Republic of China, Beijing

INDIA

Daljinder Pal Singh PARMAR, Deputy Controller of Patents & Designs, Patent Office, Controller General of Patent Designs and Trademarks (CGPDTM), New Delhi

Ram Awtar TIWARI, Assistant Registrar of Trade Marks, Trade Marks Registry, Controller General of Patent Designs and Trademarks (CGPDTM), Kolkata

INDONESIA

Erbita Dumada Riani HUTAGALUNG (Mrs.), Head of Division for Administration and Technical Services, Directorate of Patent, Directorate General of Intellectual Property Rights, Tangerang

Ika Ahyani KURNIAWATI (Mrs.), Chief of Section for Legal Advice, Directorate of Trademark, Directorate General of Intellectual Property Rights, Tangerang

MALAYSIA

Faridah KASMADI (Mrs.), Senior Officer of Trademark Division, Section Formality of Trademark, Intellectual Property Corporation of Malaysia, Kuala Lumpur

Mohammad Amran ABAS, Assistant Registrar, Patent Division, Intellectual Property Corporation of Malaysia, Kuala Lumpur

MONGOLIA

Alimaa PUNTSAG (Mrs.), Trademark Examiner, Industrial Property and Copyright Division, Intellectual Property Office of Mongolia, Ulaanbaatar

Tsoggerel PUREVJAV (Mrs.), Patent Examiner, Industrial Property and Copyright Division, Intellectual Property Office of Mongolia, Ulaanbaatar

PHILIPPINES

Lolibeth MEDRANO (Ms.), Assistant Director, Bureau of Patents, Intellectual Property Office of the Philippines, Makati City

Vina Liza Ruth CABRERA (Mrs.), Director, Management Information Service Bureau, Intellectual Property Office of the Philippines, Makati City

SRI LANKA

Chandima Deeptha Bandara Eramudugolla R.B. WASALA MUDIYANSE
RALAHAMILLAGE, Research Officer, Marketing & Business Development, Industrial
Technology Institute, Colombo

Dilini Nadisha RATHNAYAKE (Mrs.), Intellectual Property Technical Assistant, Patent and
Industrial Designs Section, National Intellectual Property Office of Sri Lanka, Colombo

THAILAND

Nithi KRISANAPHAN, Assistant Head, PCT Receiving Office, Department of Intellectual
Property, Nonthaburi

Vachra PIAKAEW, Registrar, Trademark Office, Department of Intellectual Property,
Nonthaburi

VIET NAM

Phan Thanh HAI, Deputy Director, Invention Division No.1, National Office of Intellectual
Property of Viet Nam, Hanoi

Thi Ha NGUYEN (Mrs.), Examiner, International Trademark Division, National Office of
Intellectual Property of Viet Nam, Hanoi

II. SPEAKERS

Masahiro Hashimoto, Director General, Trademark, Design and Administrative Affairs
Department, Japan Patent Office, Tokyo

Takae OTA, Manager, Intellectual Property Department, Sekisui Chemical Co., Ltd,
Kyoto

Takaki NISHIJIMA, Partner, Nakamura & Partners, Tokyo

III. ORGANIZERS

Japan Patent Office (JPO)

Toru YAMAZAKI, Deputy Director, International Affairs Division, General Affairs
Department

Yoshihiro NAKAYAMA, Assistant Director, International Affairs Division, General Affairs
Department

Azusa UTSUNOMIYA (Ms.), Administrative Officer, International Affairs Division, General
Affairs Department

World Intellectual Property Organization (WIPO)

Neil WILSON, Director, Functional Support Division, Brands and Design Sector

Takashi YAMASHITA, Director, PCT International Cooperation Division, Innovation and Technology Sector

Maria-Antonieta DE ICAZA (Mrs.), Head, WIPO Japan Office, Development Sector

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